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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:

T. HATTORI, et al.

Serial No.:

NEW

Filed:

APRIL 20, 2006

For:

POSITIVE PHOTOSENSITIVE RESIN COMPOSITION, METHOD

FOR FORMING PATTERN, AND ELECTRONIC PART

PRELIMINARY AMENDMENT

Mail Stop: NEW APPS
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

April 20, 2006

Sir:

Please amend the above-identified application, concurrently with the filing thereof, and prior to calculation of the filing fee, as listed in the following, and as set forth on the following pages:

AMENDMENTS TO THE SPECIFICATION;

AMENDMENTS TO THE CLAIMS;

REMARKS are included following the amendments; and

An Appendix containing a Substitute Specification and a marked-up copy of the original specification showing amendments made thereto, follows the Remarks.